

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Patent Application of:

Yueh, et al.

Application No.: 10/750,042

Filed: 12/30/2003

For: A Low Outgassing and Non-
crosslinking Series of Polymers for EUV
Negative Tone Photoresists

Examiner: Amanda C Walke

Art Unit: 1752

Commissioner of Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

In response to the Office Action mailed April 20, 2007, herein referred to as "The Office Action," applicant respectfully request that the above-identified application be amended as set forth below. Applicant request continued examination of the application pursuant to 37 C.F.R. § 1.114.